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Application Number:	10713172					
Filing Date:	14-Nov-2003					
Title of Invention:	CRACK AND RESIDUE FREE CONFORMAL DEPOSITED SILICON OXIDE WITH PREDICTABLE AND UNIFORM ETCHING CHARACTERISTICS					
First Named Inventor/Applicant Name:	Aaron Partridge					
Filer:	Gerard A. Messina/Elizabeth Tretter					
Attorney Docket Number:	11403/84					
Filed as Large Entity						
Utility under 35 USC 111(a) Filing Fees						
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)	
Basic Filing:						
Pages:						
Claims:						
Miscellaneous-Filing:						
Publ. Fee- early, voluntary, or normal		1504	1	300	300	
Petition:						
Patent-Appeals-and-Interference:						
Post-Allowance-and-Post-Issuance:						

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Extension-of-Time:				
Miscellaneous:				
	Tot	(\$)	1810	